



Advanced Laser Based Manufacturing Group

The UPM Advanced Laser Based Manufacturing Group focuses on the development and industrial transfer of advanced process using state-of-the-art laser sources and irradiation systems (specially those using pulsed lasers). With a wide experience in micro and nanofabrication applications using laser technology.

The group has current activity in strategic industrial sectors like energy (specially photovoltaics), electronics, automotive, biotechnology, regenerative medicine, etc.

Facilities and infrastructures





Micromachining Laser Stations

AB 200- UV nano-picoseconds:

- Spectra Physics Pulseo (DPSS Nd:YVO4, 20 ns, 20W @ 100kHz).
- Spectra Physics Vanguard (DPSS Nd:YVO4, 10 ps, 80 MHz, 350 mW).

□ ML 100- UV nanoseconds:

- ATL Laser Lasertechnik SP300i (KrF excimer 248 nm, 7ns, 5 W@300 Hz).
- Spectra Physics HIPPO (DPSS Nd:YVO4 355 nm , 15 ns, 5 W @ 50 kHz.
- □ INNOLAS Lumera Superapid-picoseconds:
 - DPSS Nd:YVO4 1064 nm/ 532 nm/ 355 nm 8 ps.
 - 18W @1064 nm / 8W @ 532 nm / 4W @ 355 nm.

Appolo Hub Workbench

□ Application Laboratory for Equipment Assessment in Laser Based Manufacturing.

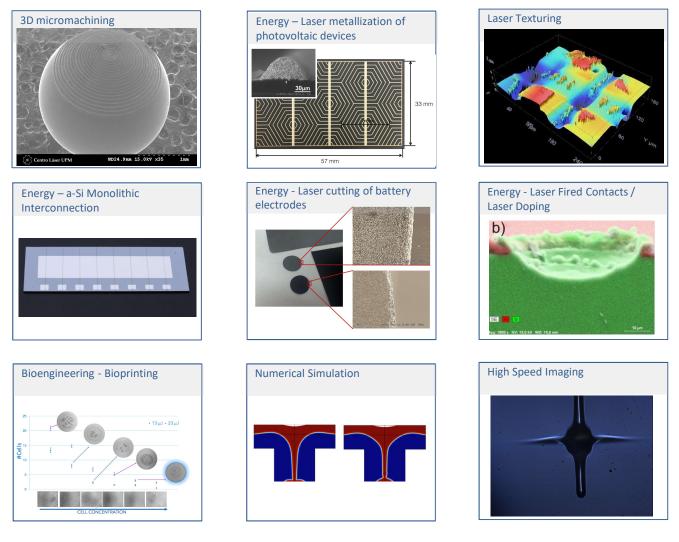
Biological Lab Facility for Laser Bioprinting

Microscopy Facilities

- **A** Raman Microscopy Renishaw inVía.
- Confocal Microscope Leica DCM 3D.
- □ Scanning Electron Microscopy Hitachi 3000 N (SEM-EDX).



Research areas associated with Big Science



Main projects in Big Science

 FP7 APPOLO Hub of Application Laboratories for Equipment Assessment in Laser Based Manufacturing. European Project FP7-2013-NMP-ICT-FOF. 2013-2017. EPCoordinator: G. Raciukaitis (FTMC – Lituania).

Software, tools or licenses to be applied to Big Science

- COMSOL software.
- High Speed Imaging System (25 ns resolution).



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